

Attorney Docket N . 040021-0306769
Client Reference: OPP 031059 US

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: SEUNG-CHUL CHOI

Application No.:

Confirmation

No:

Filed: December 16, 2003

Group No.:

Examiner

For: CHEMICAL VAPOR DEPOSITION APPARATUS AND METHOD

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

APPLICATION DATA SHEET
37 C.F.R. § 1.76

BIBLIOGRAPHIC DATA

1. Applicant information

First applicant: SEUNG-CHUL CHOI
Citizenship: Republic of Korea
Residence: Seoul, Korea

2. Correspondence information

Correspondence for this application should be addressed as follows:

Customer No.: 00909

3. Application information

Title of Invention: CHEMICAL VAPOR DEPOSITION APPARATUS AND METHOD

Docket number assigned to this application: 040021-0306769

Suggested Classification: Class:

Subclass:

Technology Center to which subject matter is assigned:

Total number of drawing sheets: 3

Type of application:

Utility

Application is to be published. Suggested drawing figure for publication:

Secrecy order under § 5.2:

This application does not disclose subject matter of an application which is under a secrecy order pursuant to § 5.2.

4. Representative information

The following have a power of attorney or authorization of agent in this application:

Customer No.: 00909

5. Foreign priority information

Foreign priority is claimed for this application as follows:

Country: Republic of Korea
Application No.: 10-2002-0080762
Filing Date: December 17, 2002
Status: Pending

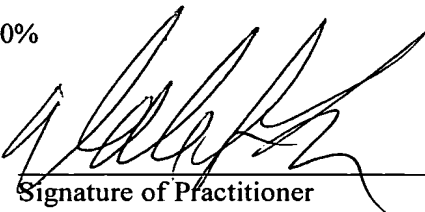
6. Assignee information

The assignee(s) of this application is/are:

Anam Semiconductor Inc.
891-10 Daechi-dong, Kangnam-ku
Seoul, 135-523
KOREA
Extent of interest of assignee in application: 100%

Date: December 16, 2003

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